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U.S. UTILITY Patent Application

PATENT NUMBER and
ISSUE DATE

APPL NUM	FILING DATE	CLASS	SUBCLASS	GAU	EXAMINER
10026653	12/27/2001	438		2812	

**APPLICANTS: Ishida Masaya; Miyazawa Takashi;

**CONTINUING DATA VERIFIED: *None*

** FOREIGN APPLICATIONS VERIFIED: *any*
JAPAN 2000-403230 12/28/2000

PG-PUB DO NOT PUBLISH ☐ RESCIND ☐

Foreign priority claimed ☒ yes ☐ no
35 USC 119 conditions met ☒ yes ☐ no
Verified and Acknowledged Examiners's initials *any*

ATTORNEY DOCKET NO
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TITLE : Manufacturing method of molecular film pattern, molecular film pattern, manufacturing method of semiconductor device, semiconductor device, manufacturing method of electro-optical dev

U.S. DEPT. OF COMMERCE PAT. & TM. PTO-435L (Rev. 12-94)

NOTICE OF ALLOWANCE MAILED		CLAIMS ALLOWED	
<i>09/27/03</i>		Assistant Examiner	Total Claims
ISSUE FEE		Primary Examiner	Print Claim for O.G.
Amount Due	Date Paid		
\$		PREPARED FOR ISSUE	DRAWING
<input type="checkbox"/> TERMINAL DISCLAIMER		WARNING: The information disclosed herein may be restricted. Unauthorized disclosure may be prohibited by the United States Code Title 35, Sections 122, 181 and 368. Possession outside the U.S. Patent & Trademark Office is restricted to authorized employees and contractors only.	Sheets Drwg.
			Figs. Drwg.
		Application Examiner	Print Fig.

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